

REFURBISHED STEPPER

Thin Film Head and Air Bearing Surfaces

The model 1700MVS is the world's most widely used thin film head (TFH) lithography tool for high-volume manufacturing.

Incorporating an advanced machine vision system and customized software specifically designed for rowbar level processing, the 1700MVS recognizes and automatically aligns to preexisting features, thus eliminating the need for special targets

Design simplicity makes the 1700MVS a highly reliable, easy-to-operate, and easy-to-maintain system. Its low initial investment cost and low operating costs also enable it to provide tremendous cost-of-ownership benefits.

The UltraStep 1700MVS features include:

- * 1.4um or optional 1.0um resolution
- * 3 x 5 x 0.090 or 5 x 5 x 0.090 inch reticle
- * Machine Vision Alignment
- * Automatic site-by-site alignment
- * Air probe electronic focus detection
- * Wafer thickness compensator
- * Broadband exposure (g/h -line)
- * Flexible field size
- * High wafer plane irradiance
- * Large depth of focus
- * Multiple fields per reticle

SPECIFICATIONS:

Wafer Size: 3", 4", 5", 6", or 8"
 Loader Type: Automation / Manual
 Computer: PC Controller w/Hard Disk
 Machine Vision: PatMax
 Uniformity: 2.5 %
 Depth of Focus: 3.0 ums @ 1.0um lines
 Depth of Focus: 7.0 ums @ 1.4um lines
 Maximum Square: 18 x 18 mm
 Maximum Aspect: 39 x 11.4 mm
 Maximum Area: 34.2 x 13.6 mm
 Reticle Size: 3" x 5" x 0.090"

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Ultratech Model 1700 Machine Vision System

Serial Number 1395
 Manufactured December, 1997
 Minimum resolution: 1.4um or optional 1.0um
 Full field or Rowbar Illumination



PC / PatMax Controller

Manufacturing label

